

ABSTRACT OF THE DISCLOSURE

Dirt, particularly of inorganic matter,
attached to a substrate, such as a glass substrate for
liquid crystal devices, is effectively removed by
5 irradiating the substrate with ultraviolet rays
including 184.9 nm and 253.7 nm in an oxygen-
containing atmosphere in advance of wet cleaning with
pure water. As a result, the wet cleaning time and
the amount of pure water can be reduced.

10

15

20

25